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| INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i> | Docket Number (Optional) FR-AM 2005 NP | Application Number Not yet assigned |
| | Applicant(s) BONNET, A. et al. | |
| | Filing Date Herewith | |
| | Group Art Unit N/A | |

U.S. PATENT DOCUMENTS

| *EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
|----------------------|-----|-----------------|------------|-------------------|-------|----------|-------------------------------|
| /R.S./ | A1 | 5,677,387 | Oct. 1997 | Bayard et al. | | | |
| /R.S./ | A2 | 5,686,534 | Nov. 1997 | Bayard et al. | | | |
| /R.S./ | A3 | 5,886,112 | March 1999 | Vaillemine et al. | | | |
| /R.S./ | A4 | 4,393,195 | July 1983 | Gaku et al. | | | |
| | | | | | | | |

U.S. PATENT APPLICATION PUBLICATIONS

| *EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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FOREIGN PATENT DOCUMENTS

| | REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
|--------|-----|-----------------|-----------|---------|-------|----------|-------------|----|
| | | | | | | | YES | NO |
| /R.S./ | C1 | 2,841,252 | Dec. 2003 | France | | | ✓ | |
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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| EXAMINER /Robert Sellers/ | DATE CONSIDERED 10/07/2008 |
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.